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Sheet	1	of	5	Attorney Docket Number			

	- 0	NON PATENT LITERATURE DOCUMENTS	
Examiner Initials* No.1		Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T ²
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